

REMARKS

The Examiner's Office Action of September 9, 2004 has been received and its contents reviewed. Applicants would like to thank the Examiner for the consideration given to the above-identified application, and for indicating the allowance of claim 17 and indicating that claims 22 and 27 contain allowable subject matter.

By this Amendment, claims 13, 17 and 21-30 have been amended, claims 16 and 20 have been canceled, and new claims 31-36 have been added. Claims 1-12, 14-15, and 18-19 were cancelled previously. Accordingly, claims 13, 17 and 21-36 are pending for consideration, of which claims 13, 17, 21 and 26 are independent. By the actions above and the remarks below, Applicants respectfully request reconsideration and allowance of all the pending claims.

Initially, Applicants have only amended independent claim 17 in order to remove a duplicate phrase. Accordingly, Applicants submit that claim 17 continues to be allowable over the prior art of record. However, Applicants take issue with the statement made in the reasons for allowance regarding claim 17, that "the method necessarily requires a particular reaction chamber configuration with no equivalence of other reaction chambers, no equivalence of cleaning gas, and no equivalence of first and second films" Specifically, Applicants are entitled to the full range of equivalents for reaction chambers, cleaning gas and first and second films as permitted by proper claim construction as set forth in case law at such time that claim breadth is construed. Thus, Applicants again respectfully request allowance of independent claim 17.

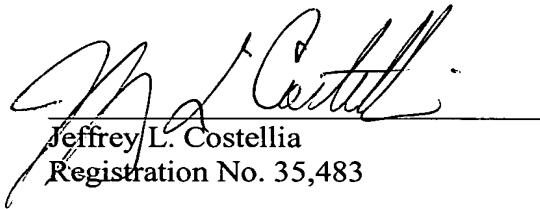
Referring now to the detailed Office Action, claim 20 is objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. By the present invention, claim 20 has been cancelled, thus Applicants respectfully request reconsideration and withdrawal of the objection.

On page 2 of the Office Action, claims 13, 16, 20, 21, 23-26 and 28-30 are rejected under 35 U.S.C. 103(a) as being unpatentable over EP 0 115 645 A2 to Fuji Xerox Co., Ltd. (hereinafter "Fuji '645") in view of U.S. Patent No. 4,539,068 to Takagi et al. (hereinafter Takagi) with U.S. Patent No. 4,563,367 to Sherman et al. (hereinafter Sherman) and WO 80/01363 to Romano-Moran. In view of the amendments provided above and the comments that follow, Applicants respectfully traverse this rejection.

Independent claims 13, 21 and 26 have been amended to recite features, believed by Applicants' to be allowable over the cited art, of allowed claim 17. For example, independent claim 13 does not recite that the substrate is placed on the first electrode as in independent claim 17. Moreover, the preamble of claims 21 and 26 are directed to a "method of fabricating electronic devices." Thus, Applicants respectfully request reconsideration and withdrawal of all the pending rejections.

While the present application is now believed to be in condition for allowance, should the Examiner find some issue to remain unresolved, or should any new issues arise which could be eliminated through discussions with Applicants' representative, then the Examiner is invited to contact the undersigned by telephone in order that the further prosecution of this application can thereby be expedited.

Respectfully submitted,



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